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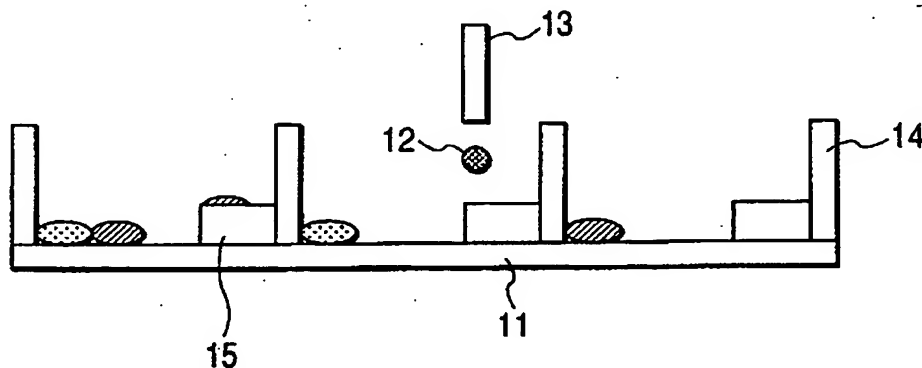
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ning of each regular issue of the PCT Gazette.

(54) Title: SUBSTRATE FOR CELL CULTURE, PRODUCING METHOD THEREOF AND SCREENING METHOD FOR CELL
CULTURE CONDITIONS UTILIZING THE SAME



(57) Abstract: A cell culture substrate having at least one area for culturing a cell on a substrate, characterized in that the culturing area comprises an area releasably holding a biologically active substance having a biological activity to the cell and an area for immobilizing a biologically active substance having a biological activity to the cell.

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